

Metastable Erbium Trihydrides Supported Films and Powders

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Introduction

The γ phase of the erbium-hydrogen system is a hexagonal trihydride that is not predicted to be stable at room temperature without an overpressure of hydrogen gas. Here, we report the creation and preliminary physical studies of both thin films and powders of erbium trideuteride that are metastable at ambient conditions.

Generalized Pressure-Composition Isotherm for Erbium-Hydrogen System



Temperature controlled gas manifold

Supplemental gas manifold

Heated reaction chamber.

Load lock and transfer arm

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Heater Quariz Chamber

Hydrogen scrubbers, vacuum diagnostics, computer controls PCT Apparatus Capabilities: 1x10⁻⁸ → 760⁺ torr 25 to 1000°C Variable Cooling Conditions H, D and HD gas mixtures available

Pressure and Temperature to be controlled to within 1%

Manual and Automatic Modes



Past PCT curves developed for the erbium-hydrogen system^[1] indicate that by loading at temperature less than 370° C and above 1 torr the γ phase is thermodynamically favored.

Extrapolating these curves to 25°C would suggest that as the γ phase is cooled down in <u>vacuum</u> it should decompose to the β phase.

[1] Lundin, C. E. (1968). "The Erbium-Hydrogen System." Transactions of the Metallurgical Society of AIME 242: pp. 903-907.

Experimental Details

Before hydriding an Erbium film or ingot, the erbia layer needs to activated at elevated temperature. XPS spectra taken of erbium films at elevated temperatures indicate a substoichiometric erbium oxide forms during the activation step. This reduced oxide likely increases the sticking coefficient of the incoming H_2 and may also play an important role in its dissociation.



Sample Preparation

<u>Er ingots</u> 99.9% Er 1 to 10 grams

<1000 ppm O_2 <300 ppm N_2 <100ppm H_2 Other rare earths <1000ppm Other metals <1000ppm



Er Films 5000 Å Er (evaporated from Er ingots)

Evaporation rate 20 Å/sec Evaporation temperature 450°C

Mo substrate chemically etched and vacuum fired



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XPS spectra of the O 1s, C 1s, and valence band regions of the erbium film surface (a) before the vacuum anneal at 450° C, (b) after the vacuum anneal at 450° C, and (c) after the vacuum anneal, trihydriding reaction at 200°C and 500 Torr D₂, and before air exposure.





Nano-indentation of ErD₃ Film Supported on Mo

ErD₃ Data fit to lower part of three indents (to avoid step-ins)

 $H = 7.3 \pm 0.6$ Gpa E = 162 ± 9 Gpa



These are deduced assuming isotropic behavior, a Poisson's ratio of 0.25 and a work hardening coefficient of 0.25.

Similar H and E found for comparable ErD₂ films.

2.0

1.0

0.0

0





[3] Gabis, I.; Evard, E.; Voyt, A.; Chernov, I.; Zaika, Yu (2003). Journal of Alloys and Compounds 356-357: 353-357

XRD Pattern for Hexagonal ErD₃ Powder - Hydrided at 250°C 300 torr D₂

[05024-02.MDI] 250oC load 300torr x2_450C anneal overnight - overnight run



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To learn about hydrogen site occupancy and isotopic effects in ErD_3 films and powders, neutron scattering and vibrational spectroscopy studies are under way on ErD_3 , ErH_3 and $ErH_{1.5}D_{1.5}$ samples.



 GdD_3 is unstable compared to ErD_3 system. After 60 days, the GdD_3 has decomposed completely to $Gd(OH)_3$. What makes ErD_3 so special...it's very stable oxide?

XRD of GdD₃ with several hours air exposure



Conclusions



Sputtered area on a ErD_3 supported film. IBA of the blue, sputtered area has an (H + D):Er ratio of 2.1. The extrapolated decomposition pressure for ErD_3 could be erroneous *OR* the observed surface **oxides** could be preventing D from diffusing to the surface and D_2 from desorbing. UHV sputter experiments on films, shown right, suggest the later is more likely.

The **oxide** layer (observed on the films and assumed to be also present on the powders) appears to serve as a diffusion barrier under ambient conditions. Diffusion of D through the activated, substoichiometric oxide and recombination to D_2 on the oxide surface begins to occur at 200°C.



Future Path

ErD₃

200°C

Kinetic explanations (oxide thickness, surface area, etc.) for the observed hysteresis between the decomposition (ErD3 to ErD2) and the formation (ErD2 to ErD3) are being studied.

ErD₂

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Film mechanical properties versus processing history.







Thermal decomposition kinetics versus ErD₃ concentration and film "color".



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Simplified Thin Film PCT Measurement



total mass $_{\rm Er}$, V $_{\rm Tot}$ must be *minimized*.

Calibration is critical to successful PCT measurements.

Hydrogen Reaction Cell/UHV Surface Analysis System



Capabilities:

Reaction Cell $3x10^{-9} \rightarrow 1000 \text{ torr}$ 25 to 550°C H, D and HD gas mixtures available **Surface Analysis System** 8x 10⁻¹¹ torr base pressure -170 to 1000°C AES XPS (mono Al source) UPS

Reflectance IR Spectra for ErD₃ and ErH_{1.5}D_{1.5} Powders

